I’ve been building Powerpoint-based quantum computers with electron spins in silicon for 19 years. Unfortunately, real-life-based quantum dot quantum computers are harder to implement. Fabrication, control, and materials challenges abound. The way to accelerate discovery is to make and measure more qubits. Here I discuss separating the qubit realization and testing circuitry from the materials science and on-chip fabrication that will ultimately be necessary. This approach should allow us, in the shorter term, to characterize wafers non-invasively for their qubit-relevant properties, to make small qubit systems on various different materials with little extra cost, and even to test spin-qubit to superconducting cavity entanglement protocols where the best possible cavity quality is preserved. Such a testbed can advance the materials science of semiconductor quantum information devices and enable small quantum computers. This article may also be useful as a light and light-hearted introduction to spin qubits.

The two states of a qubit are realized in the spin of an electron, spin up and spin down. A single electron can be trapped in a semiconductor box, called a quantum dot (Figure 1). In silicon—currently the most promising material for spin-based quantum computing—the indirect band-gap means that the electron has extra nearby energy levels, combinations of the conduction band minima or valleys where the electron exists. Temperature, noise, and gate operations can cause unwanted excitation into these states. This so-called “valley splitting” problem, especially in silicon-germanium quantum dots, impacts yield, initialization/readout, and quantum operations, and originally motivated this work. Although obscure, this materials science issue is a roadblock to quantum information processors in silicon, and valley splitting is only representative of a greater challenge. Like for other qubit parameters such as coherence time and operation fidelity, to measure the valley splitting you must fabricate a quantum dot and test it, typically at dilution refrigerator temperatures [1]. The general difficulty in making qubits in semiconductors has hampered progress in the field. Exciting recent success—functional dot qubits and compelling quantum gate demonstrations [2–10]—has taught us a lot about how to make good qubits. Yet there is a high barrier to entry for new experimental groups compared to, say, superconducting qubits.

Do superconducting qubit experimentalists have it easy? Yeah, they kind of do. The transmon qubit [11–13], which itself is robust by design [14], can be fabricated with essentially a single layer of metal, at huge length scales if wanted [15], and can be characterized and controlled with a single microwave cavity/generator/line or even wirelessly, via a properly designed superconducting cavity (Figure 2). Superconducting circuits can be floating, requiring no source or sink of carriers. In contrast, using what we know now as best principles for making a silicon quantum dot qubit (Figure 3), one needs to make very small dots (due to large effective mass), with multiple layers of overlapping or tightly-aligned metal gates to limit cross-capacitance between dot gates [16] and to increase yield due to disorder, all with O(10 nm) wire-widths at 50-100 nm wire pitch. Worse, the materials stack (causing current leakage between the top gates and electrons, disorder, etc) can be critically important to whether the quantum dots you want can even be formed where you want them, let alone will they work or have desirable qubit properties. Spin quantum dot qubits also need multiple physical wires per dot, in addition to nearby charge sensors (for spin-to-charge conversion-based readout). This level of complexity in fabrication—which must be coupled with good materials science properties of the wafer and the gate stack—retards both new qubit exploration and characterizing many, individual quantum dots to optimize materials parameters.

We can separate the materials science challenge from the “making the dots and measure them” challenge. If the dots and associated readout circuitry can be made on another circuit chip or board, then the actual electron(hole)-hosting wafer can be optimized separately (and even made of different crystals such as germanium). The idea of “flip-chip” engineering has already been applied in the superconducting context [17–18], while the concept of a “probe” trap has been used in ion trap quantum computing [19–20] to search for heating mechanisms on relevant surfaces. We hope to motivate a new kind of testbed where dots are induced on a separate chip to characterize materials [21] and to see if the protocols we design for qubit operation work. In doing so, an acceleration of progress similar to that driven by the “wireless” 3D transmon (Figure 2c) could be replicated in the spin community.

* or, How to make semiconductor-based quantum computers without fabricating quantum dot qubits; Based on talks I gave at the ARO/LPS Quantum Computing Program Review, August 2018, and 4th School and Conference on Spin-Based Quantum Information Processing, September 2018.

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We can make a quantum dot qubit without fabricating a quantum dot

A spin qubit is formed from the Zeeman split sub-levels (see Figure 1) of the ground state of an electron trapped in some potential inside a semiconductor. That electrostatic potential can be artificial, formed from the combination of a heterostructure and an external voltage, or natural, the pull of an implanted donor. One or more electrons or holes can be placed in a dot to form a single qubit or a qubit can be “encoded” into the large Hilbert space of multiple separate quantum dots, and each approach has different potentially useful properties for quantum computing. Typically, we focus on 1 or 3 electrons per dot in a roughly parabolic potential in the plane of the two-dimensional electron gas (2DEG) or inversion layer, where the potential must be deep enough such that the excited state orbital levels (“p-like” envelope functions) are well above the energy of thermal excitations (~kT). For indirect band-gap conduction bands where electrons live (or valence bands where holes live, which can be considered spin-3/2 particles), there can be other nearer levels than the orbital levels which one may also need to worry about. Somewhat surprisingly, the spin splitting (linearly proportional to the magnetic field) can be smaller than the effective temperature, and typically is in many experiments. Kramers degeneracy (where a “forbidden” very tiny matrix element connects phonons between the two spin states) results in extremely long lifetimes for spins in some solids, a fact that has been known at least since the 1950s.

In designing a quantum computer based on quantum dots we care about a number of intrinsic parameters derived from the quantum dot potential, material and material stack, and the proximity of other qubits/defects/oxides/gates, and still other parameters that are more relevant for two qubit operations. These include the level structure of the dot (or spectroscopy of the excited states), the spontaneous decay time (called the T_1 time, almost always due to emission of a phonon at these dilution refrigerator temperatures, but more complicated above ~1K), and the decay of the coherence of the qubit as a function of time (or T_2 for the specific 1/e time assuming an exponential fall-off, which is actually not usually the case). All these parameters can change with the number of particles per dot and if multiple dots are coupled together, either via the Pauli exchange interaction or capacitively (more on this below).

Let us now design the simplest quantum dot, using best practices from recent progress (Figure 3). Our options include semiconductors such as GaAs, silicon, germanium. GaAs has spinful nuclei, leading to poor T_2 times (~ns). Germanium is interesting. But the pull of silicon is strong due to the CMOS industry (ultrachemically pure and perfect crystals, precision lithography, dielectrics) and the fact that isotopically enriched silicon exists and is available (where the spin-1/2 Si nuclei have been removed leaving only spin-0 silicon-28), leading to extremely long coherence times.

First, create an electrostatic trap for the electron in z by making either a “quantum well” or an inversion layer. For the former, use a strain-engineered SiGe-Si-SiGe sandwich. For the latter, use the well-known oxide-silicon (MOS) interface of silicon and silicon-dioxide. An accumulation gate (positive voltage) creates a triangular-like potential, pulling electrons (if available) up the top surface of the buried quantum well (Figure 1). In either case there are no electrons until we put them there (assuming no doping). The effective mass of electrons in silicon is relatively high, meaning that to get an orbital splitting of ~1meV = 10K, we need an effective “box” of ~30 nm laterally. Finally, a combination of negative (depletion) and positive (accumulation) gates can form the trap in the (x,y) plane creating our dot potential. Because of the large effective mass of electrons in silicon compared to GaAs, the community has learned...
that unwanted “dots” (think a disordered eggshell container) can form in the quantum well via the presence of donors, or by possibly tiny strain due to metallic gates on the surface. Therefore, don’t dope the quantum well; implant donors in source regions creating a bath of electrons that can be brought electrostatically near the active quantum dots with gates. And make the gates as uniform (“total coverage”) and as far away as possible. This is how the best arrays of lateral quantum dots for qubits are fabricated today (Figures 2b and 2c courtesy M. Devoret, Yale.)

All we really need to induce a dot potential, however, is a single wire with a positive potential with the appropriate geometry and distance from the target active layer. This can be formed from a metal gate on the dot wafer surface, or by a wire on a different chip or probe tip. Indeed, Scanning Tunneling Microscope (STM) tips have been used in the past to induce dots on the surface of materials. This is the core of our proposal: make the dot gates on a separate chip. Thus, the simplest dot we can imagine actually doesn’t require fabricating a dot on the “dot chip” at all. We can fabricate the “dot inducing chip” or gate chip on a separate substrate, with a single layer of metal. We can then place that perpendicular to the “wafer chip” (touching or not) to where the dot is actually intended to be created. All the circuitry we need to measure the dot can be off the wafer chip under test.

Consider three options for loading electrons into the induced quantum dot (Figure 4). One, from the bulk by shining light with energy above the band-gap on the wafer, Figure 4h, (often done to ensure that the well was populated or to increase density in the 2DEG and is also common practice in STM experiments), through light background doping (not recommended), or a doped back gate reservoir. Generate enough carriers and our dot will trap one (or more, depending on the depth of its trapping potential). Two, Figure 4b, we can move the gate tip to an implanted region on the wafer, and physically move the loaded dot away from it to isolate the dot. Three, we add another lead to the gate-chip, a much wider and fatter “bath” gate (Figure 4d) that can bring electrons into the channel from the implanted region to the dot much like is already done. Implanting is a standard procedure and requires a mask but can be outsourced, and of course leaves the wafer, well, implanted. (So we’ve broken the non-invasive pledge for options two and three.)

**Characterizing an induced quantum dot**

We must confirm that the electron is present in the induced quantum dot to have a qubit. If the dot is truly isolated with only one wire to both maintain the potential and probe the dot, that is really hard to do. Best practice for qubit measurement or readout is to create a nearby quantum dot charge sensor (see the top-down SEM image in Figure 3 for an example), tuned to the edge of a Coulomb blockade peak for maximum sensitivity (small charge redistributions in the qubit dots affect the current flowing through the dot sensor). By pulsing the electrons in the dots one can figure out how to convert the spin information to different charge distributions, detectable with the readout dot with high sensitivity. However, since we only have a single wire, a better option is to use so-called dispersive readout, which should be called quantum capacitive or curvature readout. Here, a tank circuit is attached to a nearby dot gate, and small changes in the quantum capacitance (or more generally the curvature coupling) of the system are detected by measuring the phase shift of a reflected rf-pulse (dispersive shift of the resonator) at the resonator frequency (where the frequency is relatively low, 100 MHz to 500 MHz). But note that this technique as applied so far has only worked in two ways: one, detecting a signal when electrons tunnel in and out of a nearby bath (so-called “tunneling” capacitance) or two, at a charge transition (eg 11 to 20, see Figure 8 for a preview) to a nearby dot (where the quantum capacitance is detected, the curvature of the two-dot, one-electron system is maximal at the degeneracy point, the symmetric state of a charge qubit). Thus if this condition is met, standard techniques can be applied to map out 0, 1, ... electrons in the dot. A higher-frequency resonator can also be used as in (in these cases for cavity-QED not quantum
capacitive readout) putting the cavity into the quantum regime. We calculated in Ref. [21] that it may be possible to measure the small energy band curvature (Figure 5a) due to a single, stationary electron as compared to no signal (no electron trapped). Assuming the use of a superconducting resonator in series with the dot-inducing gate, quantum capacitances as low as 0.01 attoFarad should be observable if a $Q \sim 10^9$ can be achieved (see [21] for details), allowing for the detection of electrons with a single lead without tunneling transitions to a reservoir or dot (which has never been seen before). It could also be that if the measurement apparatus is fast enough then the appearance of an electron from the bulk (due to light-created carriers for example) may be observable. If these don’t work, then using the bath gate or a nearby dot (a 2 dot probe) will be necessary, slightly complicating our approach but making all the known techniques for qubit characterization available.
With the electron number in the dot known, let’s focus on spectroscopy, or charting of the excited states of the dot, as doing so solves our original problem of measuring the valley state across a chip non-invasively. Ref [21] proposes solutions for a single wire. The magnetic field that equals the valley splitting energy, there is an anti-crossing which results in a quantum capacitance change. With two electrons in the dot, the curvature is even larger and occurs in the ground state (Figure 5). Detecting this curvature allows the valley splitting to be measured by sweeping the magnetic field (or valley splitting via $E_z$) over a smaller range. Doing precise spectroscopy requires a relative energy scale. The magnetic field provides that if it can be well calibrated. Another option is to introduce another rf field which drives transitions in the dot. Unfortunately, given the large possible range of valley splittings, and the possibility of very large orbital splittings (up to 8 meV), tunability of the microwave field would have to be over a vast range for a single dot. With two dots a new energy scale emerges, the detuning between the two dots, and there are many more options; valley spectroscopy can be achieved without a magnetic field [55]. The reflectometry approach allows one to measure the critical parameters of the system even if the excited states are much larger than the cavity frequency and for arbitrarily high valley splittings in a two dot system.

To summarize, with a single wire we can detect if there is an electron in the dot and measure the valley splitting given some rather stringent requirements. There are other ways to measure valley splitting: already demonstrated techniques like photon assisted tunneling, that involve multiple dots or tunneling to leads. Those can also be realized in multi-lead systems.

**Characterizing an induced quantum dot quantum computer**

It’s straightforward to imagine a one-dimensional array of dots induced by a gate-chip on a chip wafer. Illustrations of such systems are shown in Figures 6 and 7. While it is possible to make two dots with just two wires, and for many years the community relied on detuning of energy levels between dots to produce two-electron interactions, now it is understood that using the barrier gate to control electron wave function overlap is better. It allows for operation at a sweet spot (symmetric operating point) [56, 57] and it is less sensitive to charge noise than the plunger gates above the dots [58] (the exchange interaction is less sensitive to the tunnel barrier than to the detuning, so charge noise is minimized by using only high speed lines on the barrier if possible). Doing so will
allow us to measure dot qubit quantum properties such as coherence times and even do quantum operations, that is, make a small quantum computer.

Let’s quickly go through a sequence of experiments that would characterize the wafer in question (Figure 8). With a multi-wire device it is natural and preferable to use a bath gate to load electrons. In this context our first experiment is to chart out the charge stability diagram for loading electrons from zero. To do this we vary $V_{P1}$ versus $V_{T1}$, where $V_{P1}$ is the dot gate and $V_{T1}$ is a tunnel gate between the bath and the dot. One should see lines in this plot indicating the transitions between $n-1$ and $n$ electrons (Figure 8a). (The straighter the line the better, it indicates small cross capacitance of the gates. Curviness means changing cross capacitance which is very bad because the electron is moving. It also makes it harder to dynamically compensate for such gates.) Once we can reliably load single electrons, then charge stability diagrams (P vs. P, see Figure 8p) would be performed to map out the parameter space of the two dot system. Then we can do quantum measurements.

To do quantum coherent measurements we need to actually measure the spin qubits. Incorporating readout allows one to experimentally determine the coherence time ($T_2$) and lifetime ($T_1$) of the qubits as well as the error rates of one and two-qubit operations with the right pulse sequence. Combining quantum capacitive readout with Pauli-blockade gives a proven means of differentiating the singlet versus triplet states of the two dots. If you detune the dots into the Pauli-blockade regime (where the (1,1) state equals the (0,2) state of the double dot system), one can distinguish singlet from triplet: the singlet state will tend to allow two electrons to go into the lower dot, when the combined the dots are in the triplet state, they will each stay in their respective dots as the transition won’t be allowed. This is sensitive to a readout window given by the temperature and the singlet-triplet relaxation time, but the signal can still be strong.

Another option for qubit readout, as advocated by us recently, is to attempt quantum curvature readout deep in the (1,1) regime, where the curvature of the singlet and triplet states is detected within the S-T relaxation time. This approach has the benefit of being quantum non-demolition (the qubit is preserved) and the symmetry of the dot decreases sensitivity to charge noise and increases S-T relaxation time (because the transition dipole matrix elements between S and T vanishes). It should also be noted (although this is the first place we have noted it), that this approach has some immunity to temperature - so may be the most compatible readout approach for high temperature qubits in relatively small magnetic fields.

Exchange is the fundamental interaction between electrons related to the Pauli exclusion principle that allows for fast two-qubit gates with large ON/OFF ratios. As changing the gate potentials results in the electron wave functions in the two dots overlapping, the spin state of the combined system evolves. If this interaction is timed just right a given two-qubit spin operation can be achieved resulting in an entangling gate between the qubits. Primitive quantum operations can be performed by measuring Rabi oscillations when the tunnel barrier is lowered to turn on the exchange interaction. The latter, if done at the symmetric operating point, allows one to characterize the charge noise of the device as once you turn on exchange, the spins are no longer “protected” to noise on their wave functions. More oscillations are better. A useful variant of this latter experience is to perform a fingerprint plot (see Figure 8).

Caveat Emptor

Ideally, not only would this proposal enable easier experiments, the separation of material optimization from qubit formation and control will allow us to push the limits of possible fidelity, or yield, or valley splitting, or whatever is limited by the material properties. In practice, there are concerns in translating knowledge gained from our gate-chip induced dots as compared to the “real thing.” Even assuming the wafer has been optimized fully, there could be drastically different results when the dots are fabricated in a more scalable manner.

Materials science still matters. Fabricating the gates with the associated interfaces, dielectrics, processing steps (e.g., anneals) will affect critical parameters like valley splitting and charge noise. Complex surface physics due to the passivation of the silicon/silicon-germanium surface can create unwanted potentials on the quantum dot plane in the quantum well case or a charge noise environment different than or worse than a full gate stack. Our hope is that the surface can be treated in such a way to minimize negative impact.

The gate-chip and dot wafer may not be intimately
Multi-dot experiments that characterize the system (a) Loading electrons into a single dot by changing the plunger gate above the dot versus the tunnel gate from the electron bath, also called the charge stability diagram of a dot (P vs. T plot). (b) Charge stability diagram of a double dot system for a given tunnel barrier choice (P vs. P plot). (c) Upper plot shows coherent exchange oscillations for a given tunnel barrier choice as a function of detuning between the dots. At the symmetric operating point (SOP) or zero detuning of the two dot potentials the number of coherent oscillations is enhanced $6 \times 67$. The lower plot shows a so-called “fingerprint” plot demonstrating the dependence of exchange on $\Delta$ and $V_{T2}$. In this plot the average singlet probability is shown after evolving for 500 ns at a potential specified by the axes $[5]$. (Both c plots courtesy HRL.)

connected (although they could be mounted that way). Therefore, shaking of the gate-chip will result in the moving of the electrons (with some symmetry). We have not seriously considered the possible implications of this vibration on dot and quantum operation parameters, although any length scales of movement are likely much larger than the dots, and a much lower relevant frequency compared to gate speed (nanoseconds). There can also be a vacuum penalty: if the wire is too far from the surface than the potential of the dot can be washed out. Our point design simulations indicate that 10 nm separation still allows for sufficient dot confinement (while STM tunneling typically occurs ~1 nm from the surface distances, ~10 nm can be gauged with a field emission current).

The approach still requires dilution fridge temperatures unless the qubits can operate and be operated on at higher temperature (more below). Qubit operations (e.g., an encoded CNOT gate made up of 20+ pulses) are just as difficult control-wise. Cross capacitance may be better or worse as compared to the “metal everywhere” current preference. Metal shields above and below the dot gates may be needed to decrease cross capacitance or improve screening.

Only a linear array of qubits is possible which limits scalability. Introducing longer distance couplers can connect arrays in a 1.5 dimensional geometry. To keep things simple we have discussed one layer of metal on the gate chip but the concept can get more complicated (wafer to wafer integration instead of perpendicular chips; multiple layers on the perp chip, etc) if the basic idea pans out in experiments.

What would I do?

Physics. Using the gate-chip approach can enable many relevant and interesting experiments.

1) Let’s characterize quantum-relevant wafer properties, especially valley splitting, charge noise, and disorder, across enough wafers and “devices” to be statistically conclusive.

2) Investigate proposed qubit approaches, encodings, and operation protocols. There are too many unexplored proposals to enumerate, but we still don’t understand in practice which qubit encodings offer the best trade-offs for qubit quality and classical overhead (number of dots, pulses, etc). In particular, I’d love to see our proposals for encoded qubit interconversion and noise-insensitive always-on, exchange-only qubits validated or dismissed. A 6-8 dot device would be sufficient to implement the vast majority of qubit and gate proposals.
3) Explore alternative readout and coupling approaches: transverse versus longitudinal coupling, cavity-QED versus quantum capacitance. Already discussed above.

4) Investigate different materials for their relevance to quantum computing: Optimizing valley splitting: various proposals have been made to increase valley splitting. Because all of them depend on the microscopic details of the heterostructure stack, many devices will need to be measured to have confidence in a solution. Holes: Holes exist at the Gamma-point of the valence band, so there are no valley splitting issues (although there may be spin-orbit bands nearby). Germanium: germanium has a lower effective mass for holes (as compared to electrons in silicon) which would relax the gate wire pitch requirements (and sensitivity to disorder); using holes may offer larger spin-orbit coupling as well as no complicating valley splitting physics. III-Vs: Although III-Vs suffer from spinful nuclei, they offer a benefit of a direct band gap. The gate-chip approach would allow continued research in III-Vs for optical conversion or for other materials, such as GaN. II-VIs: II-VIs offer the potential for quantum well dots with spin-0 nuclei and a direct band-gap, they are notoriously difficult to fabricate. ZnO and other oxide-based 2DEGs have shown inklings of relevance to quantum devices. 2D materials such as graphene and Van der Walls heterostructures (layers of 2D materials) offer a very large phase space of possible dot implementations (with such materials, loss may be minimized), the approach here would greatly accelerate exploration of such materials. Topological materials: Many topological materials are fragile to lithographic and gate processing. In proximitized superconducting-semiconductor stacks, there are opportunities to explore different approaches to qubit formation via the split-chip approach presented here.

5) Study high temperature qubits: spin qubits continue to have long coherence times even at elevated temperatures relative to the Zeeman splitting. An open question is how robust a 2-qubit gate can be at elevated temperatures (350 mK or 1-4K).

6) Search for non-QC applications of these small quantum systems, such as quantum dot-based SETs for voltage standards, this approach may allow for far easier fabrication and potentially better charge noise characteristics.

One more thing: coupling spins to a superconducting cavity

We’ve already discussed using superconducting resonators for readout, we can go further by exploring qubit entangling protocols via superconducting cavity or transmission lines. By putting the cavity on the gate-chip, see Figure 9 we can optimize for high Q. Certain entangling protocols may benefit from high-Q resonators. Resonators deposited on typical SiGe dot wafers, for example, tend to have Q’s << 100,000 as compared to millions achieved on clean sapphire or silicon wafers. A similar approach can be made with a flip-chip resonator and a traditional dot chip, but our approach should make fabrication much simpler. It should also allow networking of small qubit registers enabling a 1.5D quantum geometry.

End Speech

The introduction to virtually every silicon qubit paper goes something like this: silicon quantum dot spin qubits provide a promising platform for large-scale quantum computation because of their compatibility with conventional CMOS manufacturing and the long coherence times due to enriched $^{28}$Si material and low spin-orbit coupling, along with the possibility of high-density due to small quantum dots. The future of silicon quantum computing is strong, more-so given recent progress. Our difficulty has been that we must immediately go to the final dot dimensions just for the dots to work, we can’t push it off. Qubits need to be small, materials need to be right, and microscopic effects matter immediately. Many of these problems will eventually need to be addressed in superconducting qubits, but now you can avoid them to make progress.

It’s become all the rage to be building “quantum testbeds”. These testbeds put as many of the best qubits we have today together in order to run small algorithms, to achieve quantum supremacy. This will be exciting, and inconclusive, for some time. Going forward on this path is obviously necessary, and also toward the first true quantum error corrected logical qubit. Here I have in mind a different form of quantum testbed. My testbed can be used to improve or assess new materials stacks for qubits. It can be used to build few qubit system to test new designs. It is optimal for a materials-design-test cycle. Because it separates qubit design (gate structure) from wafer growth, it is easy to make both better simultaneously. It’s also easy to shift to a completely different type of material (e.g. holes in germanium versus electrons in silicon) with at most a gate pitch change. There’s also no reason one can’t use this approach to make small quantum computers.

In summary, please find a way to make and measure
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[1] 50 milli-Kelvin or about 60 times colder than deep space.
[7] M. Rudolph, P. Harvey-Collard, R. Jock, N. T. Jacobson, J. Wendt, T. Pluym, J. Dominguez, G. Khoury, B. Huang, A. A. Kiselev, P. W. Deelman, L. D. Warren, I. Milosavljevic, E. Kawakami, D. R. Shim and Rusko Ruskov whose foundational work is realized in Ref [21]. Thanks to Hilary Hurst who thought about this idea with me on her summer visit to LPS in 2016 as part of her National Physical Sciences Consortium (NPSC) graduate fellowship. Thanks to Bob Butera, Matt Borselli, Gil Herrera, Bruce Kane, Will Oliver, Ben Palmer, Rusko Ruskov, and Yun-Pil Shim for critical reading and comments and special thanks to Tim Sweeney for useful early conversations and motivation.

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ors, although there is significant experimental evidence that the dominant noise sources affecting dot qubits currently are local to each dot. The main benefits for spins are: 1) spins are small, so microwave gates can result in a lot of cross talk, 2) microwave gates (driving single dot single spin rotations with a magnetic field) are slow, 3) two qubit gates via the exchange interaction are fast. Terminology-wise I prefer 2-DFS, 3-DFS, etc. as denoting encoded qubits where the dots are isolated from each other when not undergoing (pair-wise only) encoded qubit operations. Other terminology is often used such as singlet-triplet qubits (for double dots) and exchange-only (for triple dots). More recently the community has been revisiting using small clusters of spins which form molecules with always-on exchange couplings between dots starting with the resonant exchange (3 dot) qubit (single sweet spot) and derivatives like the AEON qubit (double sweet spot). Because the exchange interaction is always on, these qubits are more sensitive to charge noise in their off state than an isolated spin, always, but have other potential advantages.


[32] Odd numbers of electrons keep the overall spin 1/2 but also lower the excited energy levels which can cause complications in gates.

[33] Effective mass theory lets us throw many of the complexities of actually being in a crystal under the rug and bundle that up in a new mass with associated hydrogenic-like orbital levels.

[34] G. Feher and E. A. Gere, Physical Review 114, 1245 (1959)


[38] GaAs was the physicists semiconductor and III-V heterostructures the host for the quantum hall effect, the fractional quantum hall effect (e.g., Noble prizes) and the first artificial atoms or quantum dots.


[61] The terminology of cavity-based readout of superconducting and semiconductor qubits is confusing. The literature in both communities uses the term “dispersive” readout (because the cavity is pulled in one direction or another by the state of the qubit) but the physical coupling between the qubit and the cavity may be completely different.

[62] Many qubit options from single spins to double and triple dot encoded qubits can be read out by conversion to a singlets or triplets of two dots.


[68] Yes, I wrote the bulk of this essay back in the winter break of 2017-2018, pre-supremacy.